# Study of a Clearing Electrode at KEKB - First beam test -

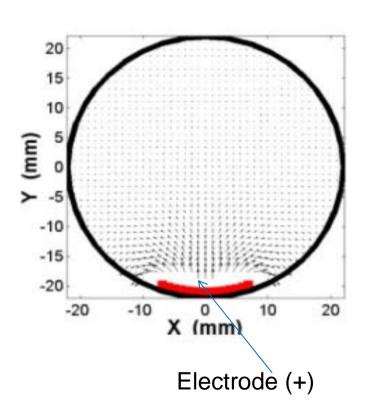
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## **Background**

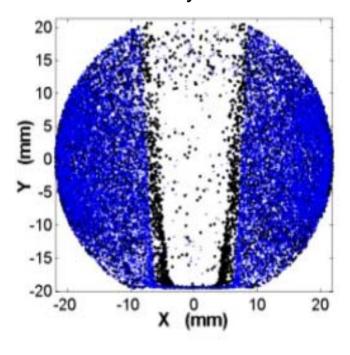
- Clearing Electrode = A possible solution to suppress electron cloud in magnets.
  - Drift space :Beam duct with antechamber (against photoelectrons) + TiN coating (against secondary electrons) + Solenoid will be OK.
- Experimental study on a clearing electrode using KEKB positron ring is planed, as a chain of ILC DR R&D study.
- Goal
  - Establish the technique of clearing electrode for ECI, which is available for high current machine and with a low beam impedance.
  - Demonstrate the effect on electron cloud formation.

# Clearing Electrode

Simulation (by L. Wang)



#### Electron density



L. Wang et al, EPAC2006, p.1489

## Test plan

 Install a test chamber with an electron monitor and a clearing electrode into a wiggler magnet of LER (Oho straight section).

At the most upstream side of wigglers

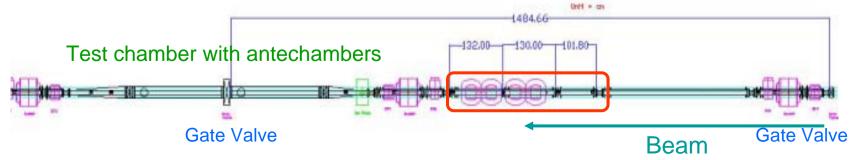
Very weak SR

– Magnetic field: 0.75 T

- Effective length: 346 mm

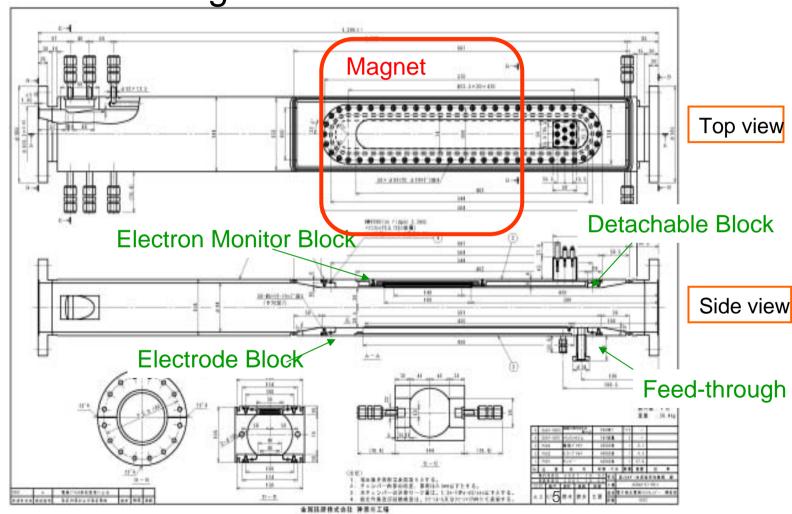
- Aperture (height): 110 mm



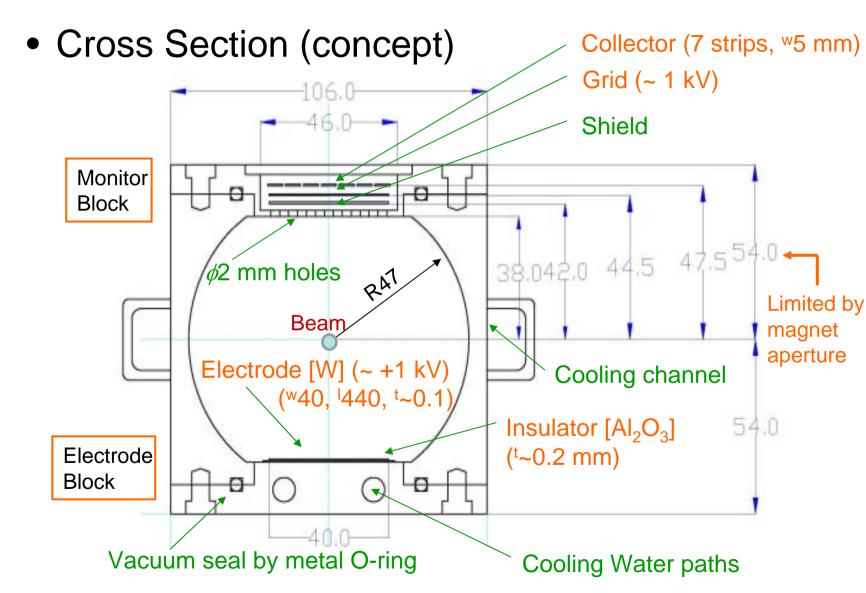


## **Test Chamber**

Over all design of the test chamber



#### Monitor and electrode



## Features of the test chamber

#### Electron monitor

- Monitor and electrode are exchangeable.
- Electron collectors are seven strips to measure the spacial distribution.

#### Electrode

- Strip type electrode.
- Very thin electrode and insulator.
  - Electrode: ~0.1 mm, Tungsten, by thermal spray.
  - Insulator: ~0.2 mm, Al<sub>2</sub>O<sub>3</sub>, by thermal spray.
    - →Small beam impedance.
- Water cooling just behind of the electrode.
  - Absorb dissipated power in the electrode and the insulator.

# RF properties

#### Model (By MAFIA)

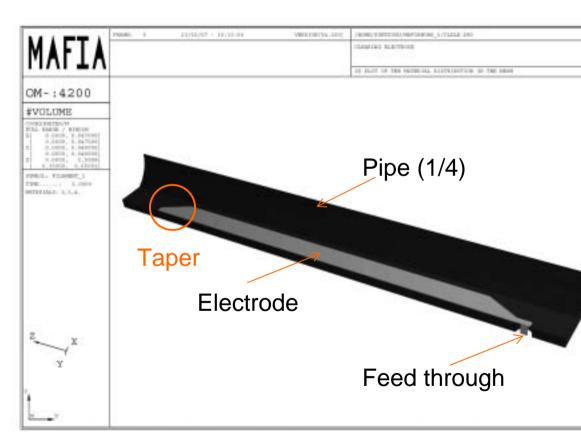
- Length = 2 m
- 1/4 model
- Electrode position = 195-625 mm (430mm)
- Width = 40 mm
- Mesh sizes =

 $0.5 \times 0.1 \times 0.4 \text{ mm}$ 

- Bunch length = 6-8 mm
- Electrode thickness =

0.2 mm

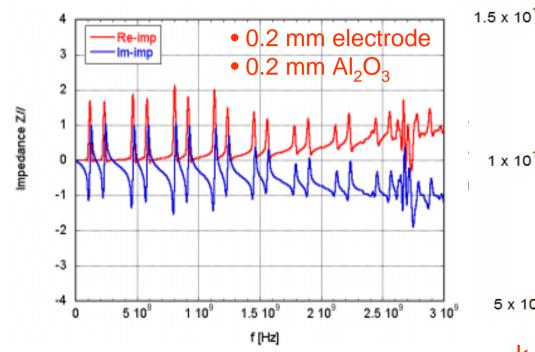
- Alumina thickness =
   0.2 mm
- Alumina  $\varepsilon_r = 9.9$
- Port = 14 mm (o), 6 mm (i)  $(50\Omega)$



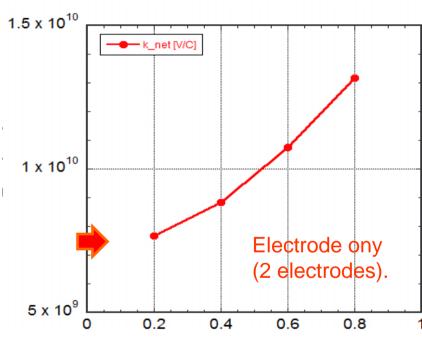
Embedded + Taper + Feed through

## RF properties

#### Impedance(z<sub>//</sub>) (by MAFIA)



 $Z_{//} \sim$  a few Ohm  $Z_{//}$  reduced to  $\sim$ 1/5 by decreasing the thicknesses



k ~1.5x10<sup>10</sup> V/C including the connection part (2 electrodes). Dissipated power is ~ 120 W for 6 electrode. (@1.6 A,1585 bunches

## RF properties

#### Voltage at feed through

• 
$$\sigma_z = 6 \text{ mm}$$

Voltage at the end of port @ 1C 5x10<sup>10</sup> 4x10<sup>10</sup> V [V] 3x10<sup>10</sup> 2x10<sup>10</sup> 1x10<sup>10</sup> -1x10<sup>10</sup> -2x10<sup>10</sup> -3x10<sup>10</sup> -4x10<sup>10</sup> -5x10<sup>10</sup> 2x10<sup>-8</sup> 3x10<sup>-8</sup> 4x10<sup>-8</sup> 5x10<sup>-8</sup> 6x10<sup>-8</sup> t [s]

At 1.6 A (1585 bunches),

Output voltage:

 $V_{O} \sim 450 \text{ V}$  (If no resonance)

 Output power from feed – through:

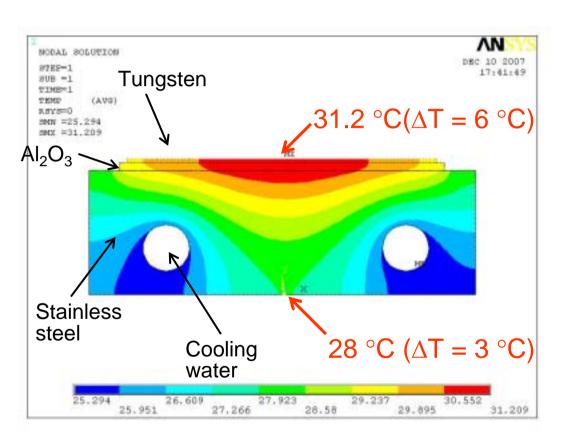
$$P_O \sim 45 \text{ W} \text{ (if R=50}\Omega)$$

 Voltage between electrode and chamber:

V ~ 9 V (If no resonance)

## Thermal calculation

For the case of 100 W input on the surface



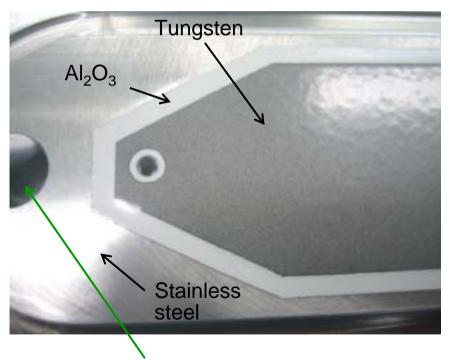
0.5 mm electrode 1.0 mm Al<sub>2</sub>O<sub>3</sub>

- Heat transfer coefficient between chamber and water = 0.01 W/mm²/K
- Temperature of water = 25 degrees.

Material	Thermal
	Conductivity [W/mm/K]
SUS	0.017
Al <sub>2</sub> O <sub>3</sub>	0.03

# Manufacturing of electrode

- Electrode = Hot spray of tungsten (0.1 mm)
- Insulator = Hot spray of Al<sub>2</sub>O<sub>3</sub> (0.2 mm)



Hole for feed-through

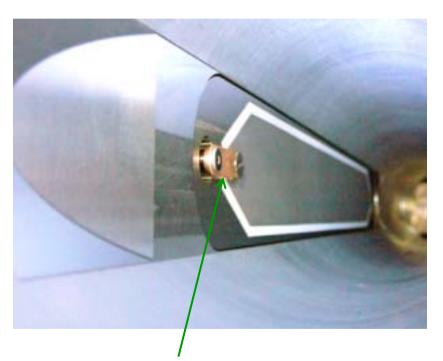


Connection between electrode and feed-through

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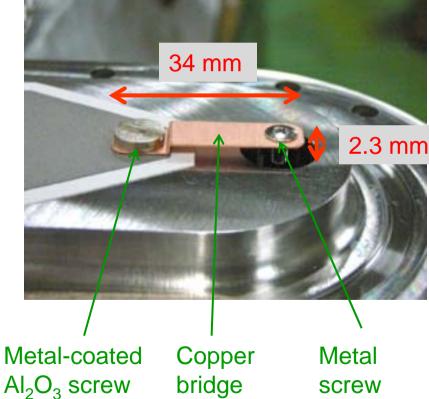
# Assembly of electrode

#### Connection part



Connection to feed-through

Bakable up to 140 °C

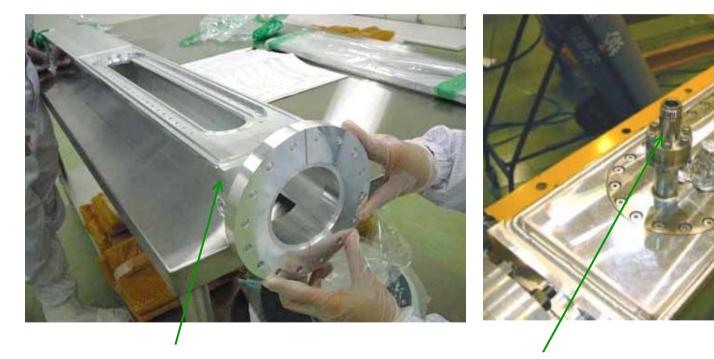


## Manufacturing of chamber

#### Test chamber

Chamber

Feed through



Aluminum-alloy chamber

N-type connector

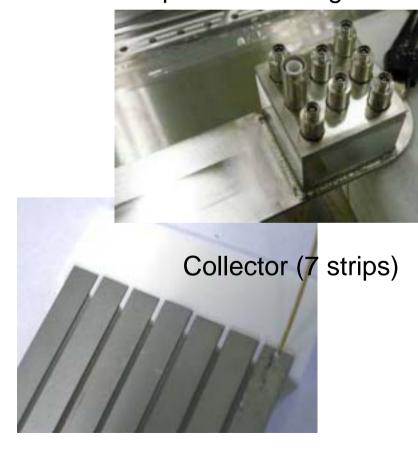
# Manufacturing of monitor

#### Monitor block

Monitor part

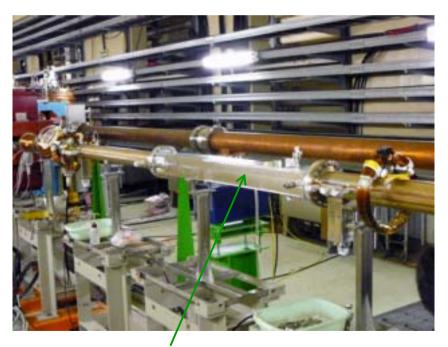


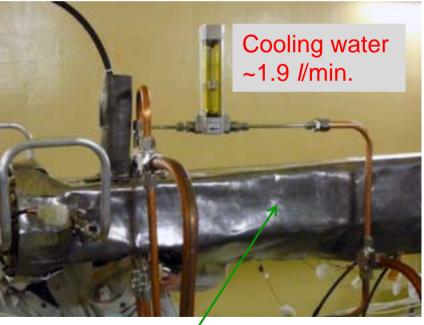
#### Output feed-through



## Installation into KEKB

- Test chamber with only electrode was installed at first in Jan., 2008.
  - To check basic properties, such as heating.
- Outside of magnet in case.



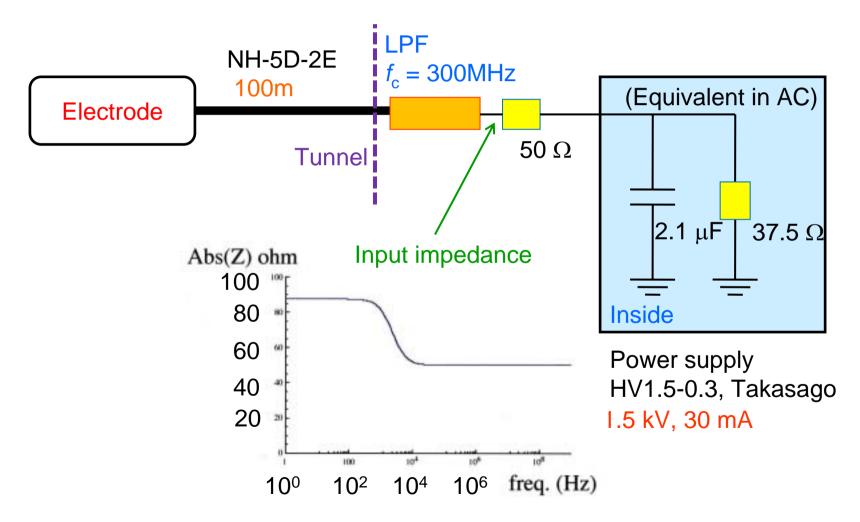


Test chamber

Lead shielding

## **Power Supply**

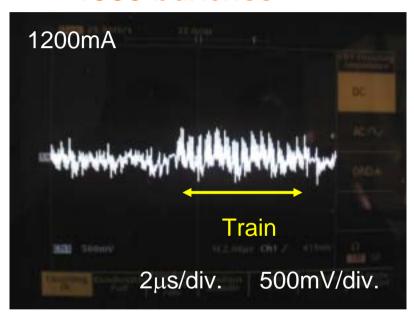
Basic configuration of power supply

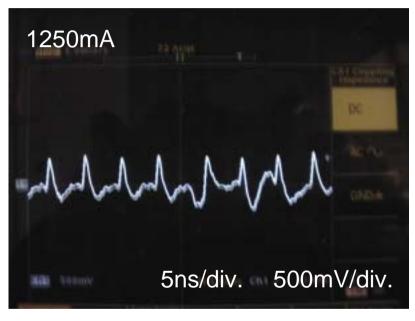


Measurement of bunch signals

1585 bunches

Without LPF



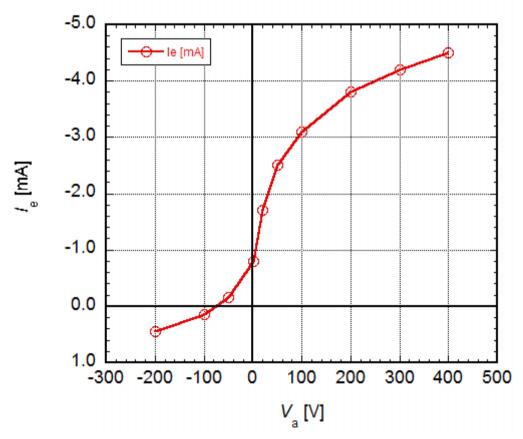


Measured: 1  $V_{p-p}$ at 1250 mA.

If attenuation of the cable is about 30db, the voltage at feed-through is about 30 V.

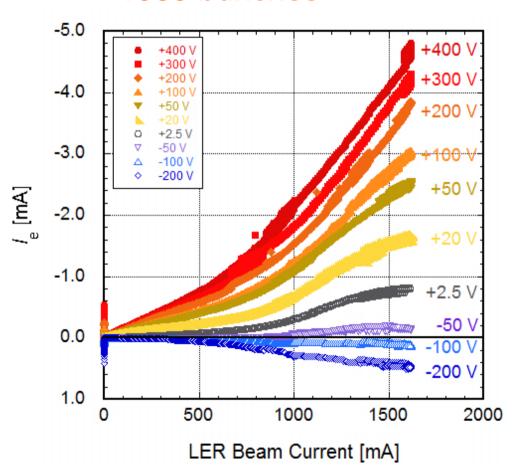
Lower than expected. Mismatch of impedance?

- Measurement of electron current (DC mode)
  - 1585 bunches, at 1.6 A



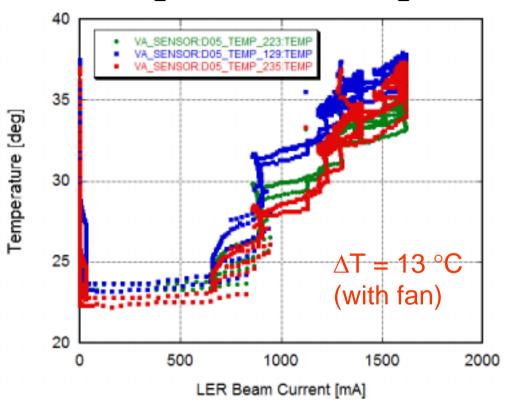
- $I_e$  increases with  $V_a$ , but slowly for  $V_a > 300 \text{ V}$ .
- Small I<sub>e</sub> for negative V<sub>a</sub>.
- →Main electrons are photoelectron from side walls.
- Photon density at the test chamber is ~2x10<sup>17</sup> photons/s/m.If the photoelectron yield is 0.2, the expected electron current is ~2.6 mA (for 0.4m).

- Measurement of electron current (DC mode)
  - 1585 bunches

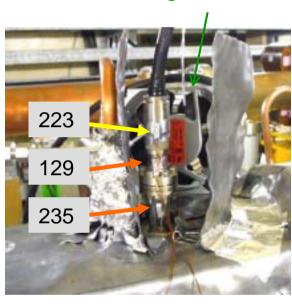


- I<sub>e</sub> dependence on the beam current approaches to a line as increasing V<sub>a</sub>, especially for high current region.
- Why? Multipactoring of electron is suppressed??
- Further study using monitor is required.

Heating of feed-through



Cooling fan



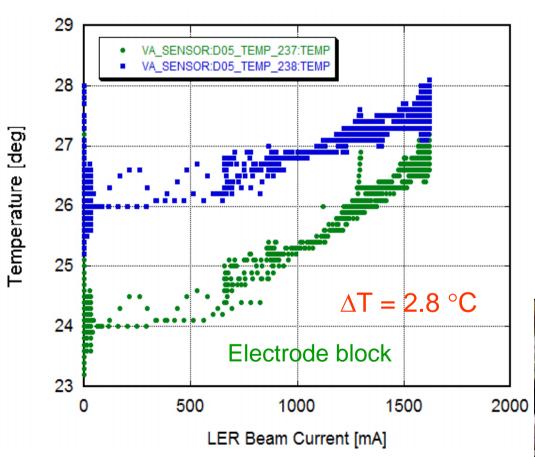
May be  $\Delta T = 100 \,^{\circ}C$  without fan

The feed-through is now cooled by air fan.

The neck will be cooled by a block with cooling water.

Heating due to mismatch of impedance?

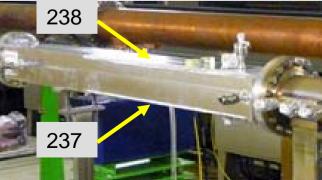
Heating of electrode block and dummy block



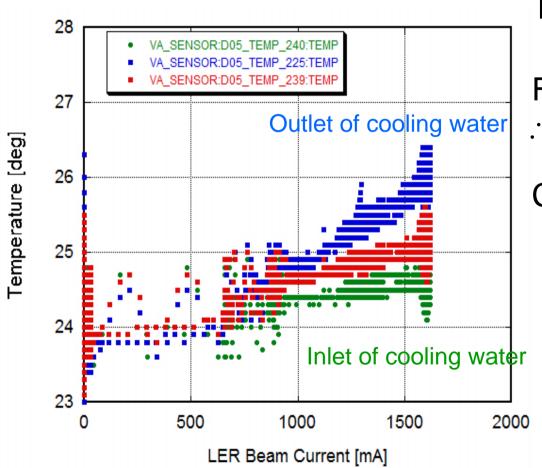
Just behind of electrode block

 $\Delta T = 2.8 \, ^{\circ}C \, @ \, 1.6A$ 

Near to expectation.



#### Absorbed power



Temperature rise:

 $\Delta T = 1.4 \, ^{\circ}C \, @ 1.6 \, P$ 

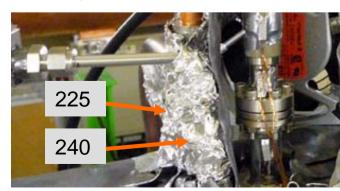
Flow rate: 1.9 l/min.

:: Absorbed power:

P = 70x1.9x1.4 = 190 W

Calculation: ~130 W

The value is reasonable considering the additional loss by tapers



# **Summary**

- Clearing electrode has been studied for a cure of EC in magnets at KEKB.
  - Thin electrode and insulator contribute to decrease the impedance.
- Beam test of the electrode started from February.
  - The heating is almost reasonable, except for that at feed-through port.
  - The behavior of electron current is reasonable.
  - The first available clearing electrode for high current (~1.6 A) and short bunch (~7mm) machine.
- Problem to be solved
  - Heating at feed through
    - Mismatch of impedance?
  - Long-term stability
    - Change of insulating resistance?

#### Test schedule



- First step (from February, 2008)
  - Install outside of magnet (upstream side)
  - Check the heating of electrode
  - Measurement with electron monitor. → Next week?
- Second step
  - Install into the wiggler magnet with electron monitor
- Third step
  - Groove surface, Rough surface, and other promising methods.

